

Investigating CMOS Based Local Bias Voltage Generation for Solid-State Qubit Potential Well Creation

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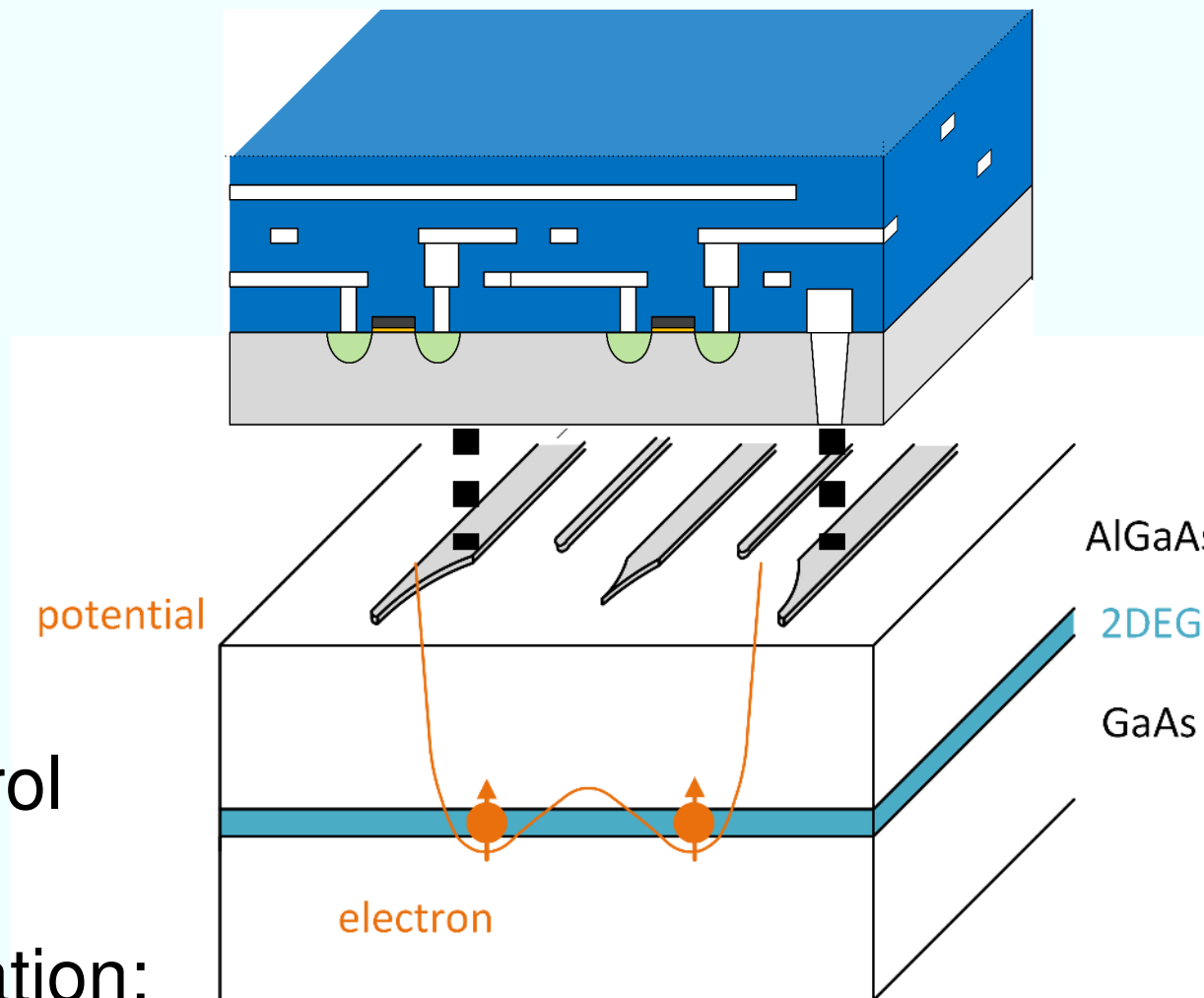
Goals & Motivation

Quantum Computer needs millions of physical Qubits^[1,2]

- Qubits operated inside a dilution refrigerator
- Number of Qubits need to increase by several orders of magnitude to build a universal quantum processor
 - Need for a completely scalable solution
 - Technology operable at cryogenic temperatures, 4 K down to 20 mK
- Integrated semiconductor based devices are promising candidates in order to meet these criteria, i.e. modern CMOS process technology

Integrate Local Classical Control Electronics with Qubits

- Long-term scalability calls for local classical control electronics:
 - Reduce number of wires fed into the fridge
 - Reduce bandwidth by pre-processing data
 - (Partly) local quantum error correction possible
- Electronics should include: bias voltage DACs, control pulses generation, readout, data pre-processing
- Top-down system design and bottom-up implementation:
 - Investigate system partitioning (RT, 4 K and Qubit stage)
 - Design specialized ICs for cryogenic temperature



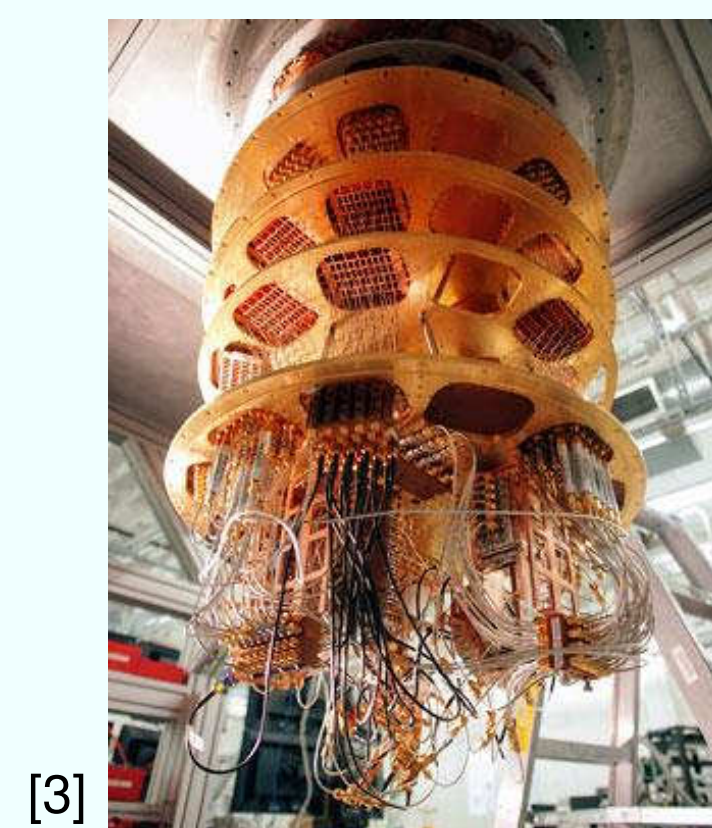
State of the Art

“Brute Force” Scaling

- Increase the no. of wires to connect as many Qubits as possible
- 7 x 7 qubits are targeted to be operated^[3]
- No full scalability to millions of Qubits

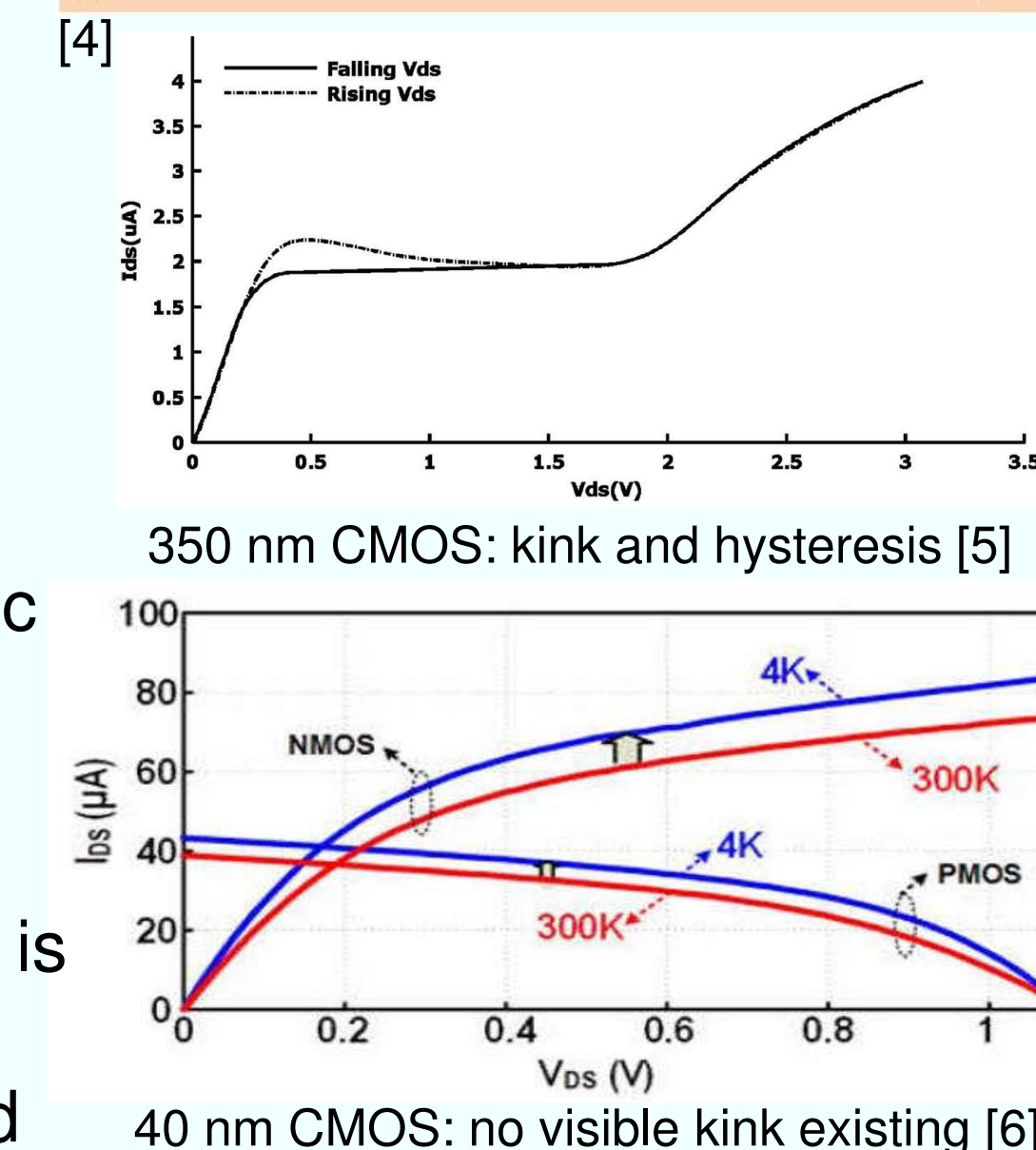
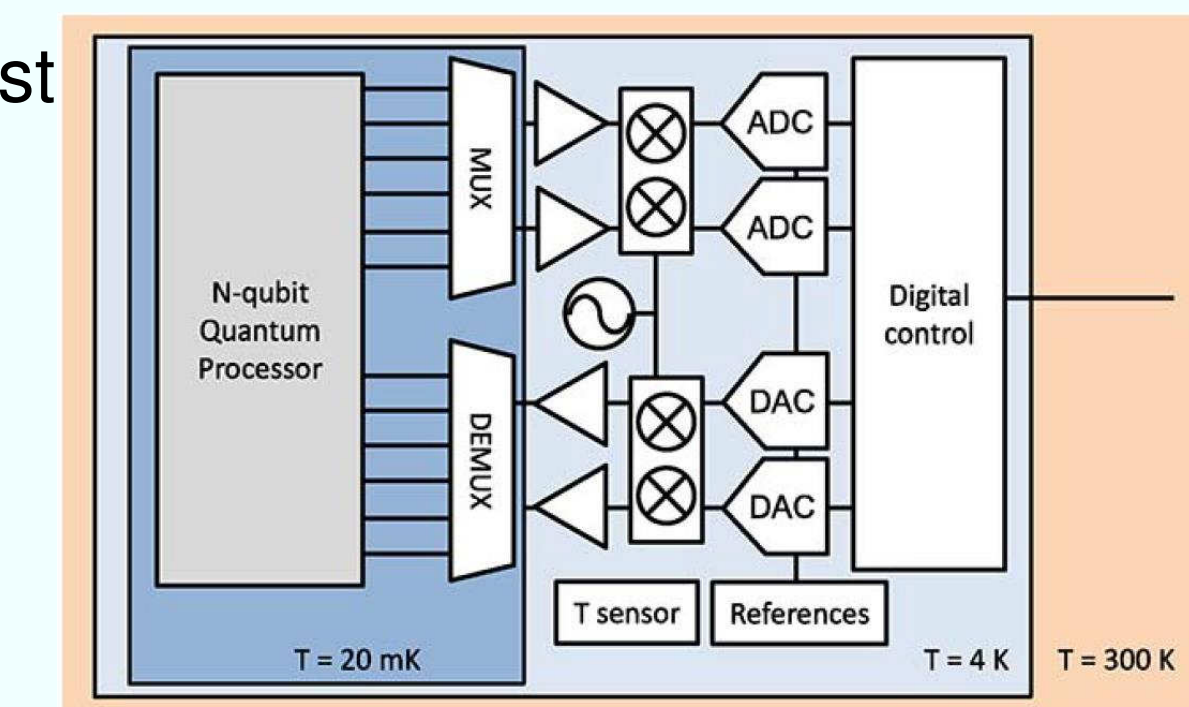
4 K Stage Control Electronics^[4]

- Ongoing research activity in order to bring control electronic into the dilution refrigerator, including use of FPGAs, ASICs and off-the-shelf components
- Only limited number of devices operated at the lowest temperature stage (e.g. MUX and DEMUX)
- Considerably more cooling power available on 4 K stage, but interconnect to Qubits via cables required
- Multiplexing used to reduce the required number of cables



CMOS Cryogenic Operation

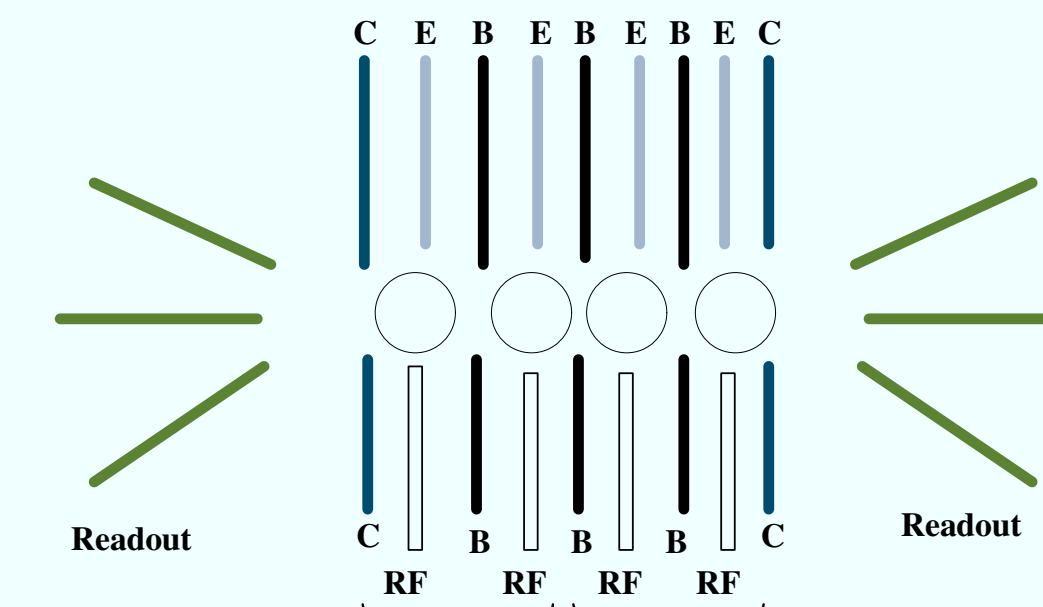
- Ultra low temperatures lead to MOSFET behavior anomalies e.g.:^[5]
 - Kink effect
 - Dopant freeze-out (<30 K)
 - V_{TH}-shift
 - I_D-Hysteresis
- Rapid increase of noise below 50 K, due to cryogenic anomalies (in 350 nm CMOS)^[5]
- Reduced kink for CMOS process nodes < 100 nm^[6]
 - Use small technology nodes
- No standard model for cryogenic MOSFET behavior is commercially available^[6]
- Modeling and fitting of CMOS parameters is required



System Level Considerations

IC for Bias Voltage Generation

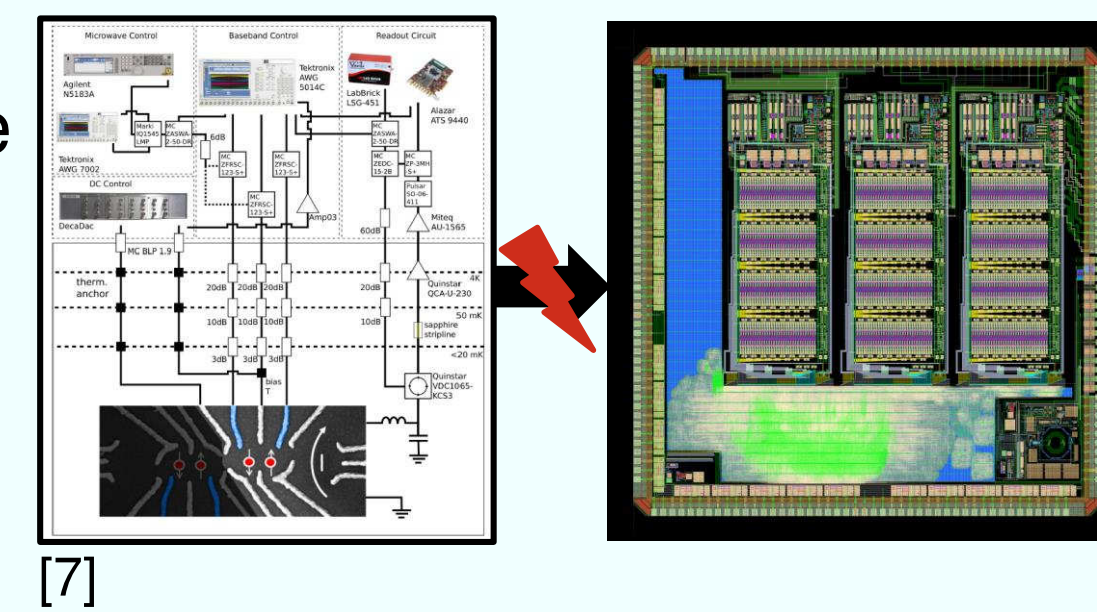
- Generate bias voltages for Quantum Dot (potential well for electrons)
- Update times in the range of milliseconds
- 5-10 DC voltages needed for one Qubit
 - Bias tee used for RF electrodes
- Voltage digital-to-analog converter (DAC)



Design Challenges

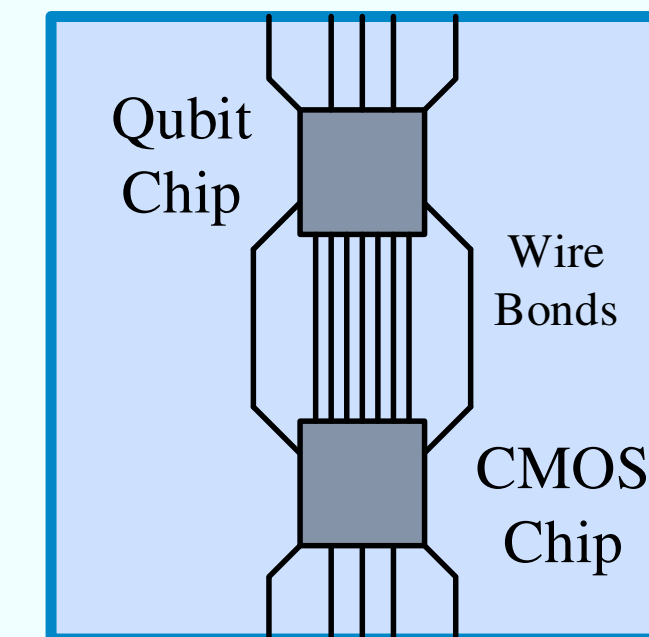
- Cryogenic operating conditions
- Ultra-low power consumption: ca. 1 mW total cooling budget at lowest cooling stage
- Extremely stable output voltages: uncertainties of less than 30 μV
- Scalable architecture (e.g. multiplexing)
- Quantitative design specifications still premature
- Include various options to tune circuit

→ Novel IC circuit architectures and approaches enabling solutions not applicable without CMOS technologies



Cryogenic IC Qubit Control Demonstrator

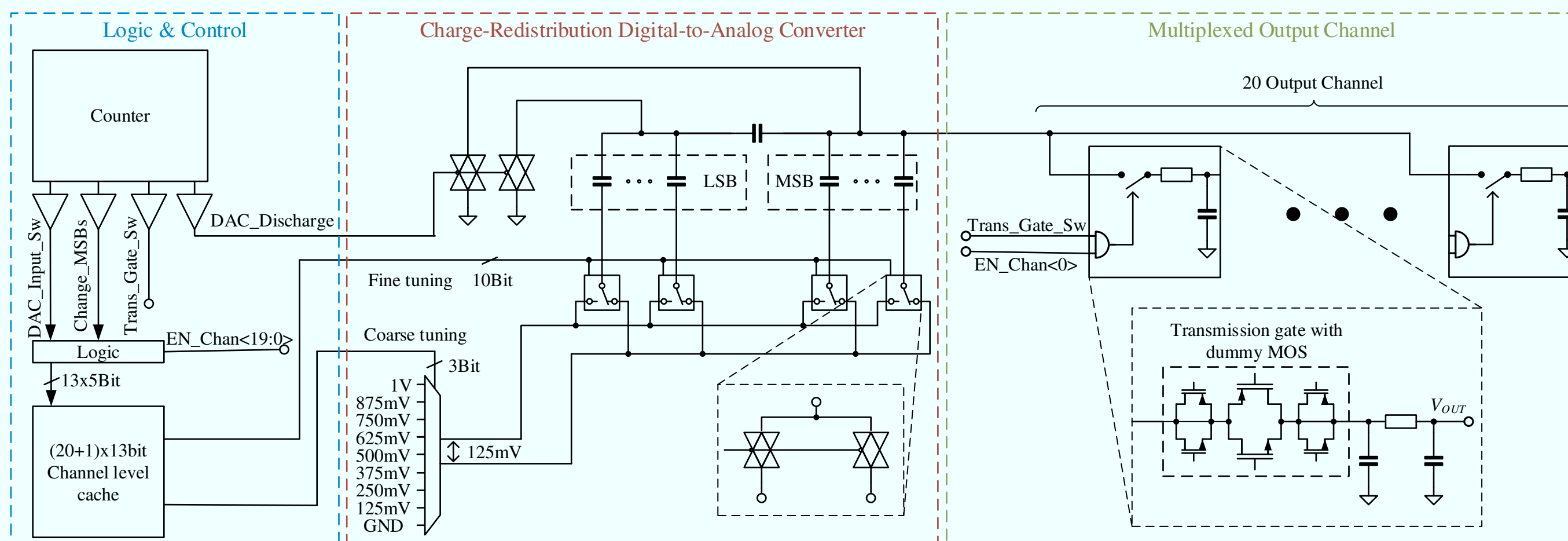
- Design of a proof of principle demonstrator in commercial CMOS 65 nm technology
- Operation on the same interposer as the Qubits
 - Lowest temperature regime of dilution refrigerator (<100 mK)
- First step: DC biasing DACs for potential well creation
- Test structures support fitting of device model parameters to cryogenic environment
- Prove feasibility of using commercial CMOS to control a Qubit and develop system concepts for full scalability



Implementation

Charge-Redistribution DAC Topology

- Utilize reduced thermal noise at cryogenic temperatures: $\bar{V}_{N,RMS} = \sqrt{\frac{k_B \cdot T}{C}}$ [8]
- Iterative charging concept implemented
- Periodical refresh needed to compensate leakage currents
- Reduce power consumption by coarse tuning reference voltages
- Multiplexing of output channels to further enhance power and area efficiency
- Passive low-pass filtering of output signals



Voltage Stability

- Simulated static operating point noise in one output channel and extrapolated data

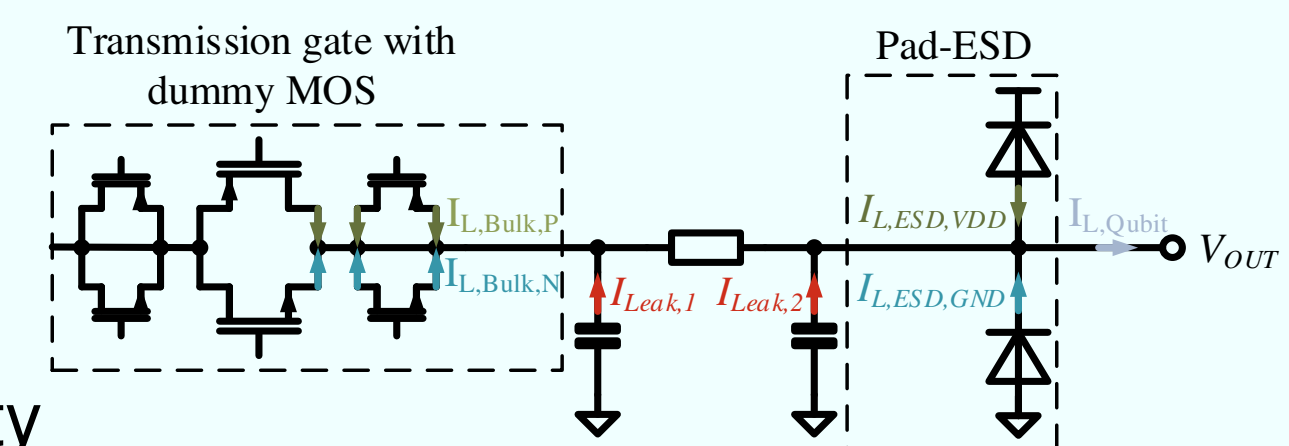
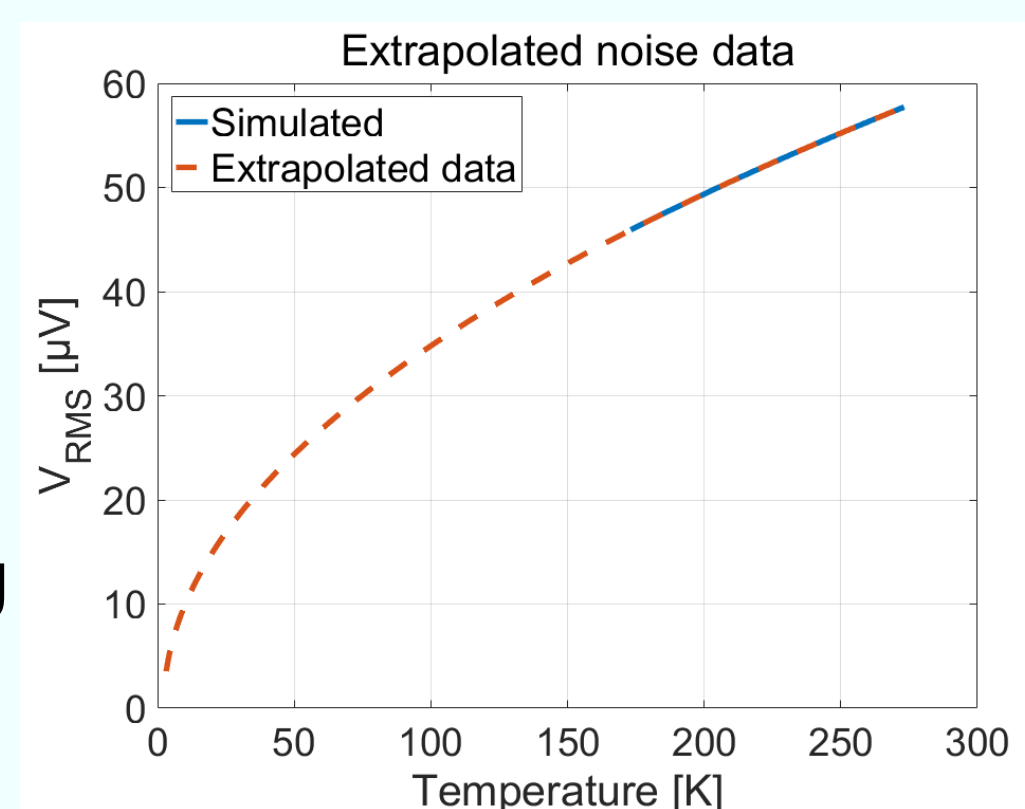
$$\bar{V}_{RMS} \propto \sqrt{\frac{T}{I_D} + T \cdot I_D + T^2 \cdot I_D^2} \quad [9]$$

Noise source: **Thermal** Channel

- Small I_D due to low current flow for refreshing (range of 5-10 nA)
- Thermal noise is main contributor
- Simulated noise at 100 mK: $\bar{V}_{N,RMS} \approx 1.3 \mu V$

$$\text{close to } \sqrt{\frac{k_B \cdot 0.1 K}{1 pF}} = 1.17 \mu V$$

- Leakage currents causing voltage drop on the capacitors
 - Tradeoff: power vs. voltage stability
 - Max. 10 μV (with process variations and mismatch)
 - ~300 kHz refresh frequency per channel
 - Simulation models do not include dopant freeze-out
 - Leakage at 100 mK expected to be negligible
 - Decreased refresh rate possible

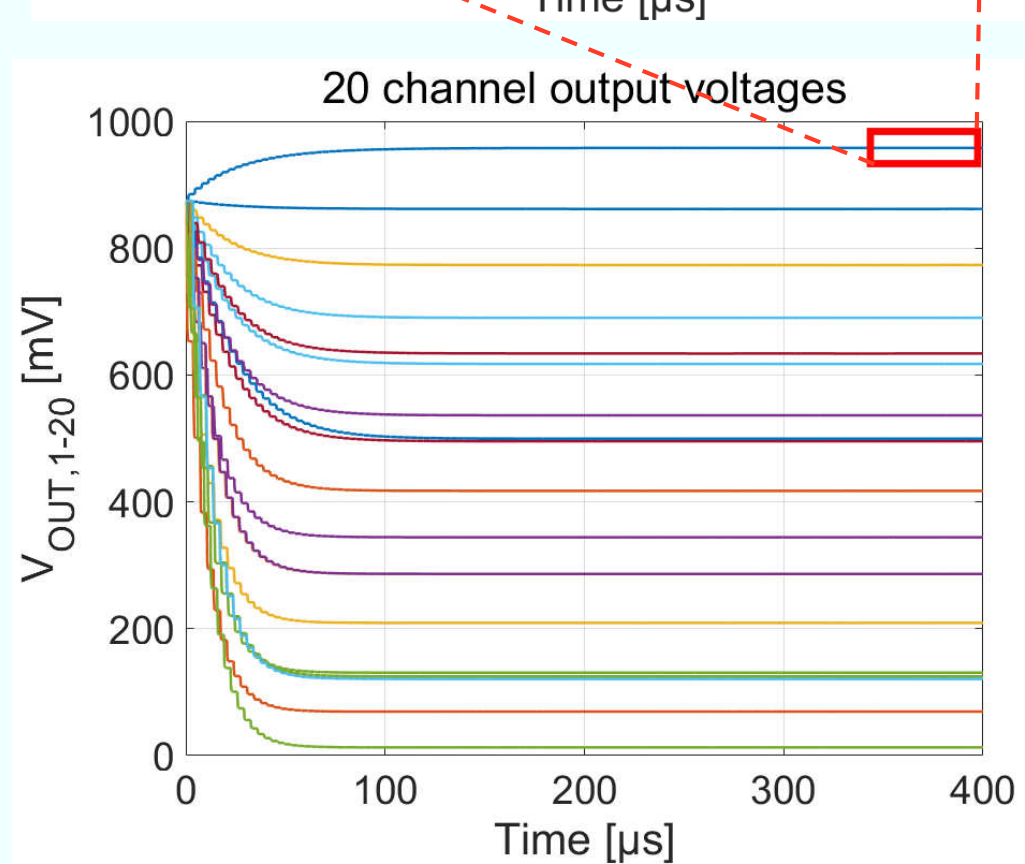
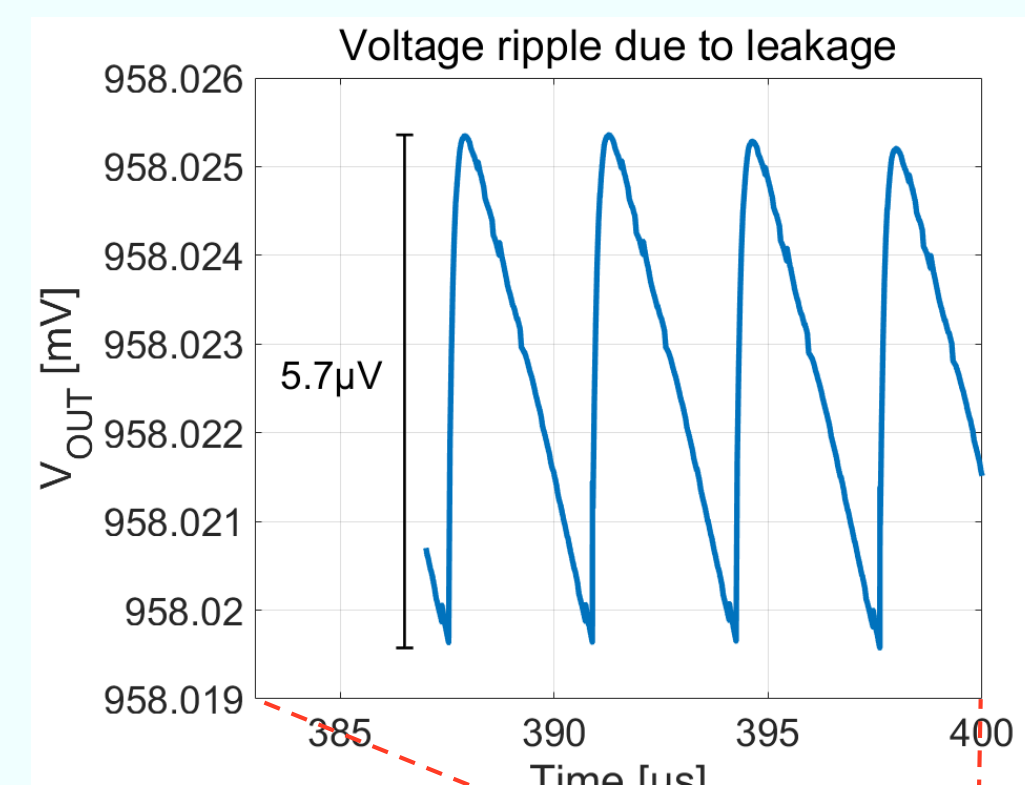


Power Consumption

- System speed defined by transmission gate “on”-time (4 ns → 125 MHz clock rate)
- Major part of power dissipated in digital logic and buffers for transmission gate control
 - $P_{Dig} \propto V_{DD}^2$
 - Reduce supply voltage
 - Dedicated cryogenic CMOS technology operating at few mV supply
- Reuse control signals for multiple DACs

No. DACs	No. channels	Power per channel
1	20	4.2 μW
5	100	2.7 μW

→ DAC architecture and global signals promise further reduction of power consumption



Conclusion and Outlook

- Promising early noise simulations indicate the potential of cryogenic ICs
- Promising early power simulations encourage the feasibility to operate multiple Qubits within given power budget
- Investigate the influence of parasitics on the supplied voltages
 - Need for ultra-low noise supply and reference voltages
- Decide on interface protocol (robustness, efficiency)
- Integration of ADC for DAC output verification on demonstrator

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 [2] R. Van Meter and C. Horsman, “A Blueprint for Building a Quantum Computer,” in *Communications of the ACM*, vol. 56, no. 10, pp. 84-93, October 2013.
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 [4] F. Sebastiano et al., “Cryogenic CMOS interfaces for quantum devices,” *2017 7th IEEE International Workshop on Advances in Sensors and Interfaces (IWASI)*, Vieste, 2017, pp. 59-62.
 [5] B. Okcan, G. Gielen and C. Van Hoof, “A third-order complementary metal-oxide-semiconductor sigma-delta modulator operating between 4.2 K and 300 K,” *Review of Scientific Instruments*, vol. 83, no. 2, p. 024708
 [6] E. Charbon et al., “15.5 Cryo-CMOS circuits and systems for scalable quantum computing,” *2017 IEEE International Solid-State Circuits Conference (ISSCC)*, San Francisco, CA, 2017, pp. 264-265.
 [7] Tim Botzern, „Coherence and high fidelity control of two-electron spin qubits in GaAs quantum dots,” PhD Thesis, p. 36, Figure 4.2.: Schematic setup. Online: <http://publications.nwth-aachen.de/record/689507>, 14.08.2017
 [8] Behzad Razavi, “Design of analog CMOS integrated circuits”, Second Edition, Mc Graw Hill Education, 2017, p. 229
 [9] BSIM4.5.0 MOSFET Model, online: <http://bsim.berkeley.edu/models/bsim4/>, 14.08.2017

